

FIG. 1

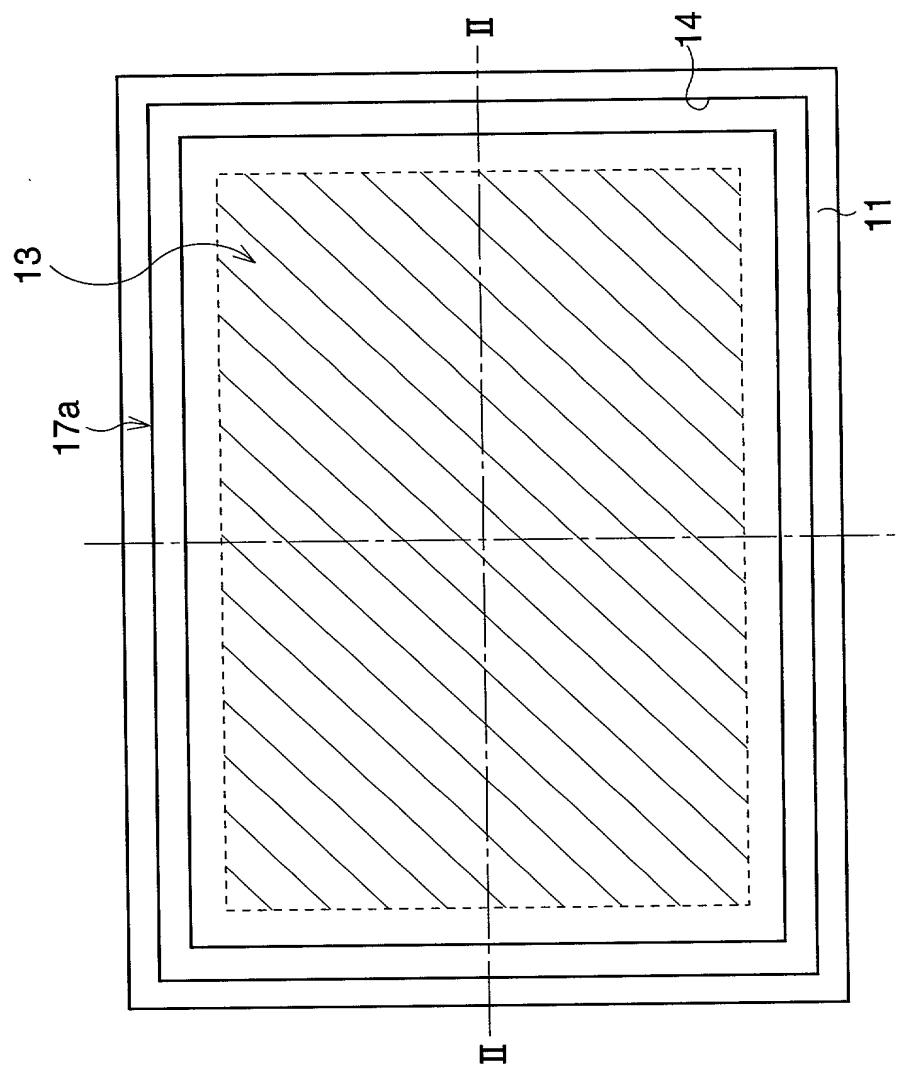


FIG. 2

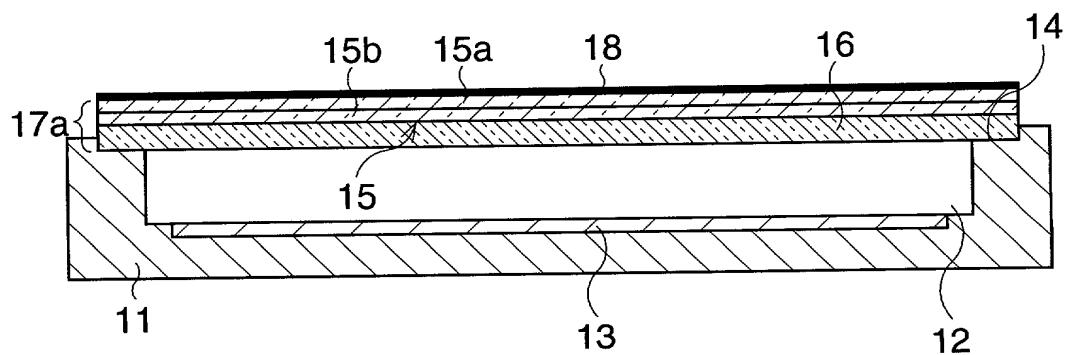


FIG. 3

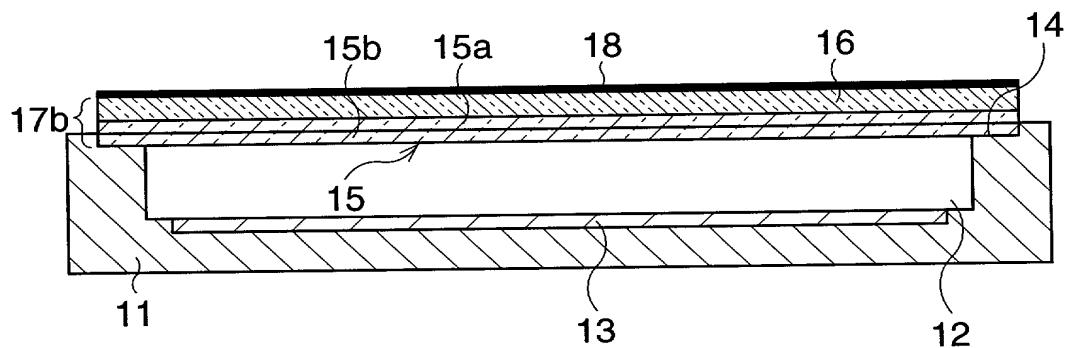


FIG. 4

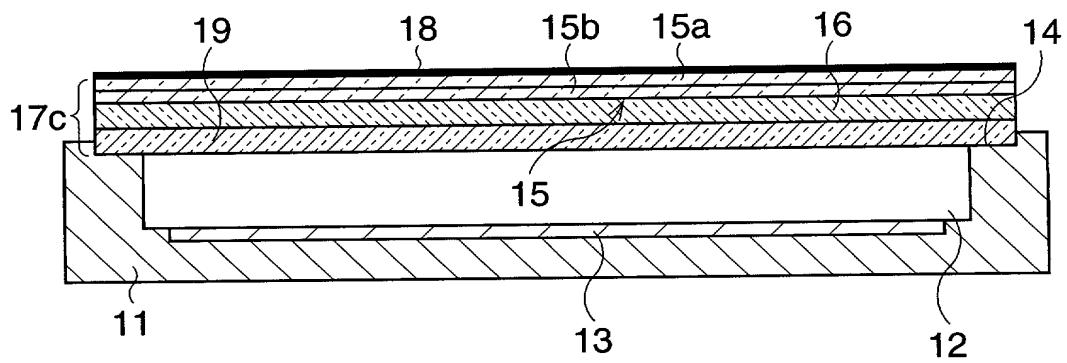


FIG. 5

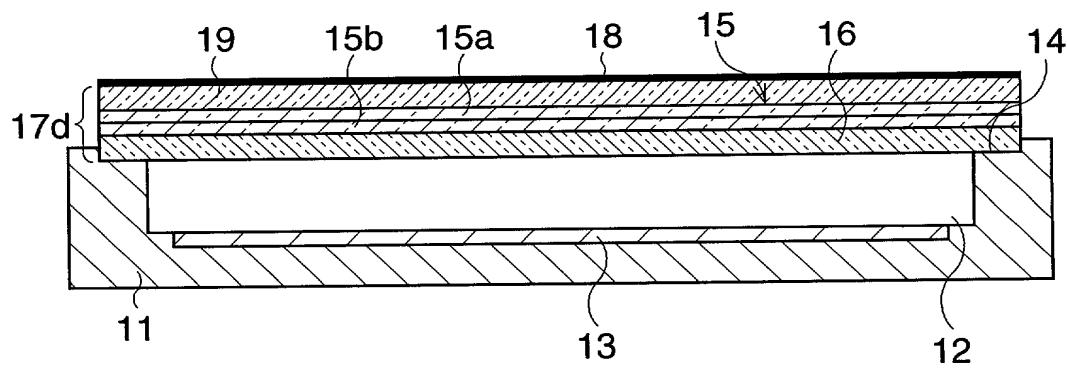


FIG. 6

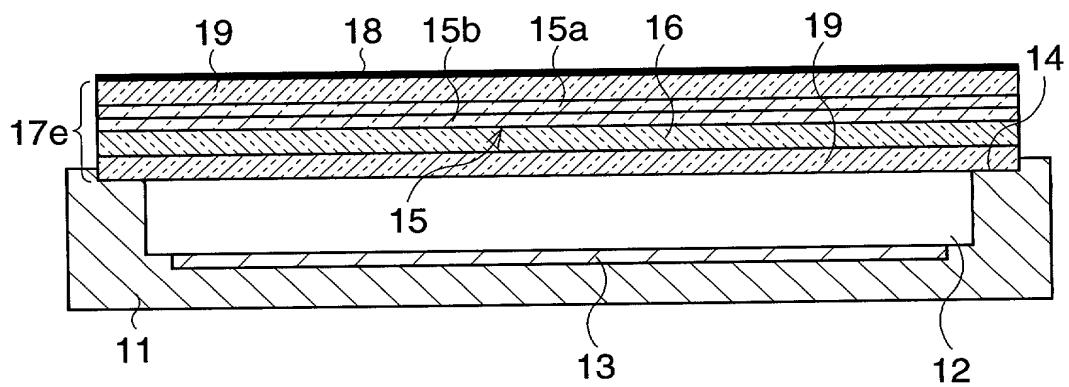


FIG. 7

CONDITION OF DEPOSITION				PROPERTY OF FILM		
	VACUUM INTENSITY	TEMPERATURE OF LN PLATE	SPEED OF DEPOSITION	THICKNESS	FILM RESISTANCE	STATIC POTENTIAL
EXAMPLE 1	$2.0 \times 10^{-5}$ torr	100°C	20nm/min	1.7nm	870kΩ	ABOUT 0.5kV ABOUT 0.1kV
EXAMPLE 2	$2.0 \times 10^{-5}$ torr	100°C	3.3nm/min	3.3nm	ABOVE 40kΩ	ABOUT 0.5kV ABOUT 1.0kV

FIG. 8

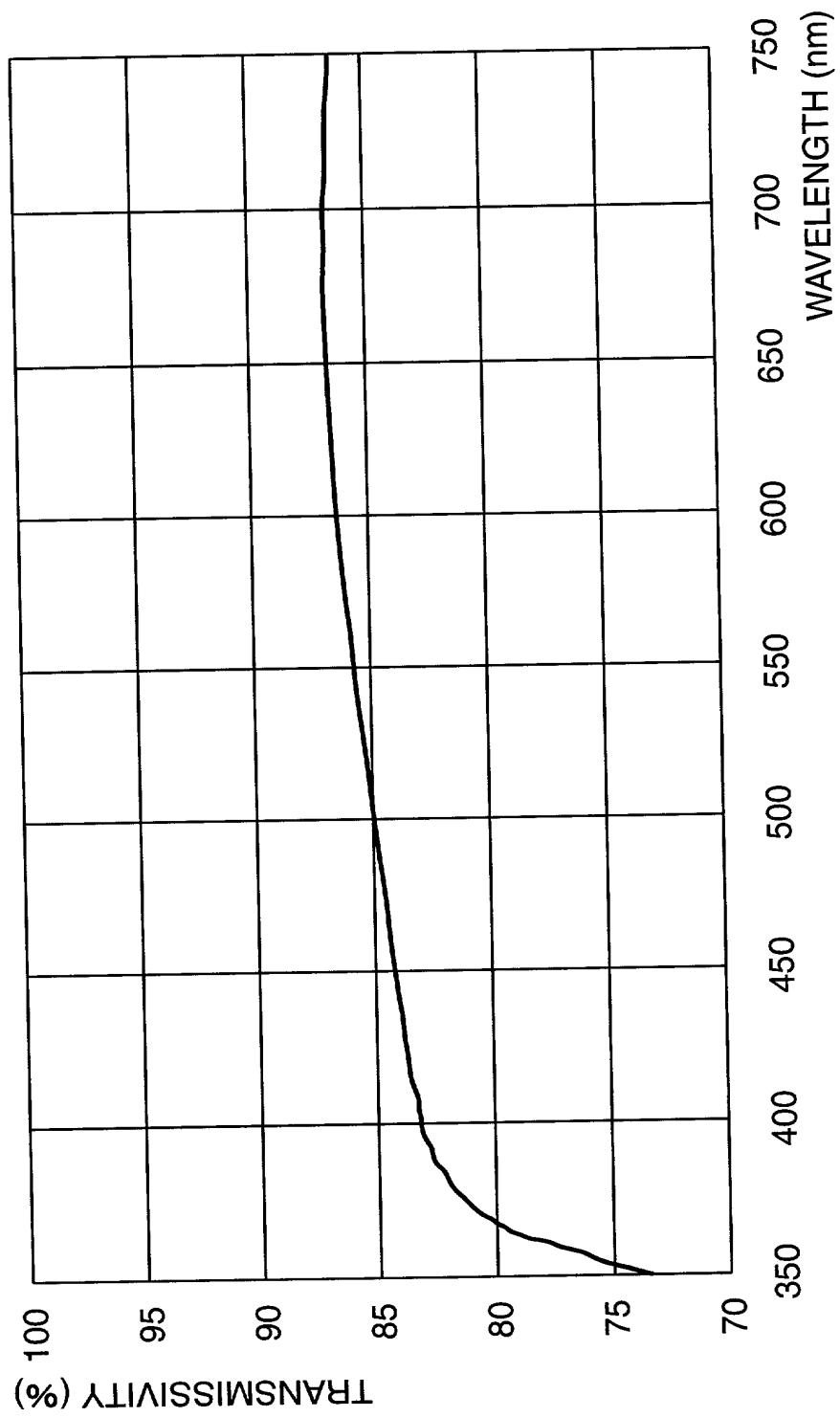


FIG. 9

